



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Daniel Alvarez, Jr. and Jeffery J. Spiegelman

Application No.: 10/692,018 Group: 1724

Filed: October 23, 2003 Examiner: Frank M. Lawrence, Jr.

Confirmation No.: 8519

For: METHOD FOR PURIFICATION OF LENS GASES  
USED IN PHOTOLITHOGRAPHY

CERTIFICATE OF MAILING OR TRANSMISSION

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, or is being facsimile transmitted to the United States Patent and Trademark Office on

12/23/05

Date

Lisa Woodbury

Signature

Lisa Woodbury  
Typed or printed name of person signing certificate

AMENDMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This Amendment is being filed in response to the Office Action mailed from the U.S. Patent and Trademark Office on August 26, 2005, in the above-identified application. Reconsideration and further examination are requested.

A one-month extension of time to respond to the Office Action is respectfully requested. A Petition for a One-Month Extension of Time and the appropriate fee are being filed concurrently with this Amendment.

Please amend the application as follows:

12/30/2005 ZJUHAR1 00000027 10692018

01 FC:1201

400.00 DP